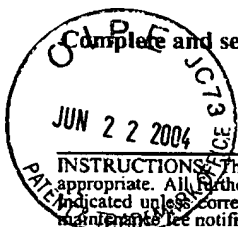


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Karen Vertz	(Depositor's name)
<i>Karen Vertz</i>	(Signature)
6-22-04	(Date)

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/645,032	08/21/2003	Gautam V. Thakar	TI-32822.1	7350

TITLE OF INVENTION: POLYSILICON PROCESSING USING AN ANTI-REFLECTIVE DUAL LAYER HARDMASK FOR 193 NM LITHOGRAPHY

APPLN. TYPE	SMALL ENTITY	ISSUE FEE	PUBLICATION FEE	TOTAL FEE(S) DUE	DATE DUE
nonprovisional	NO	\$1330	\$300	\$1630	09/15/2004
EXAMINER	ART UNIT	CLASS-SUBCLASS			
LINDSAY JR, WALTER LEE	2812	257-758000			

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1 **W. James Brady, III**

2 **Frederick J. Telecky, Jr.**

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Applicant Gautam V. Thakar et al.

Docket Number: TI-32822.1

Serial No.: 10/645,032

Art Unit: 2812

Filed: 08/21/03

Examiner: Walter L. Lindsay, Jr.

For: Polysilicon Processing Using an Anti-Reflective Dual Layer
Hardmask for 193 nm Lithography

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NAME OF INVENTOR(S): Gautam V. Thakar et al.	
TITLE OF INVENTION: Polysilicon Processing Using an Anti-Reflective Dual Layer Hardmask for 193 nm Lithography	
TI FILE NO.: TI-32822.1	DEPOSIT ACCT. NO.: 20-0668
FAXED: 6-22-04 DUE: 9-15-04 ATTY/SECY: GCH/kjv	
RECEIPT DATE & SERIAL NO.: Serial No.: 10/645,032 Filing Date: 08/21/03	

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